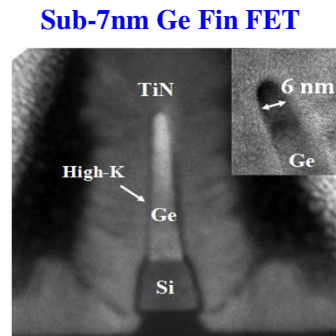
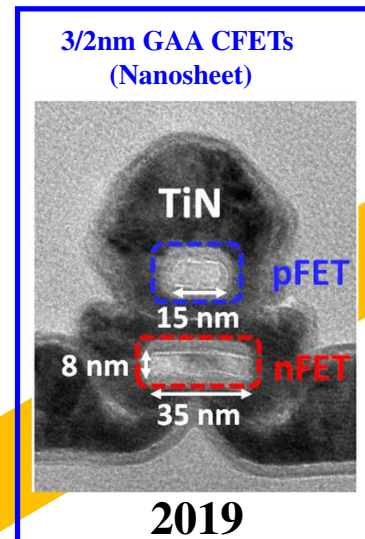


History of Collaborative Papers between Tohoku Univ., NYCU and TSRI in IEEE International Electron Device Meeting (IEDM)

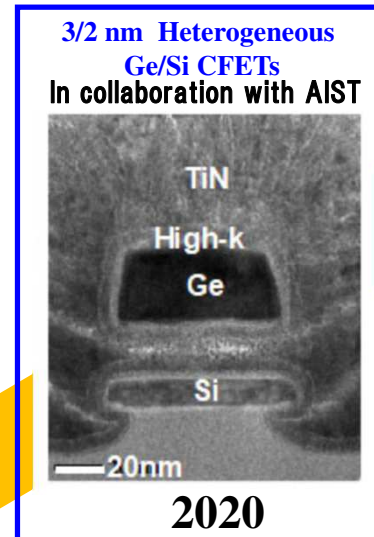
Accepted for IEDM during 3 consecutive years about the nanosheet and CFET.



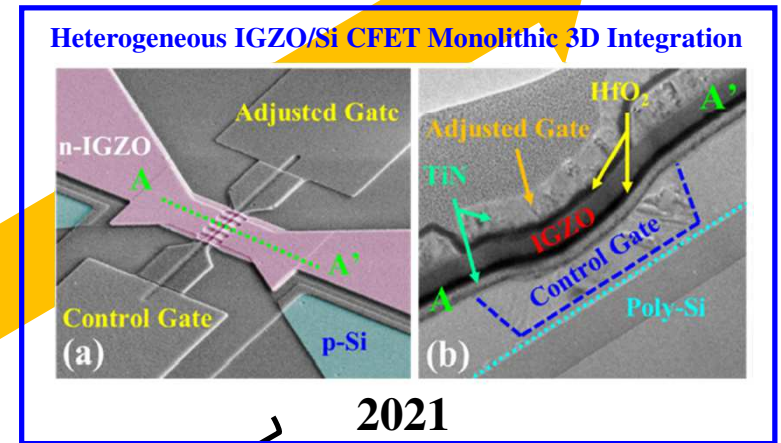
2016



2019

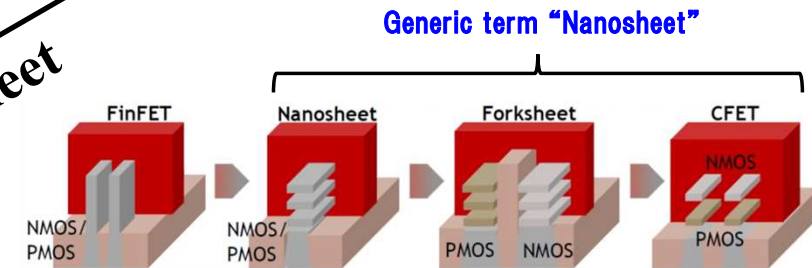


2020



2021

Nanosheet



A Member of **NAR Labs**
Taiwan Semiconductor
Research Institute

